## PRODUCTION METHOD FOR LAMINATE TYPE DIELECTRIC DEVICE AND ELECTRODE PASTE MATERIAL

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## ABSTRACT OF THE DISCLOSURE

This invention provides a method of producing a laminate type dielectric device free from peeling of an 10 electrode layer and a ceramic layer and from voids in both electrode layer and ceramic layer, and an electrode paste material. The invention relates also to an electrode paste material for constituting electrode layers of a laminate type dielectric device produced by at least the steps of alternately laminating ceramic layers 11 containing a lead element as a constituent component and electrode layers 2, and degreasing and baking the laminate, wherein the electrode paste material contains CuO as a principal component of a starting material of an electrically conductive material, a solvent, a binder, and a cooperative material consisting of at least one kind of the main components constituting the ceramic layer 11.